IN THE U.S. PATENT AND TRADEMARK OFFICE Patent Application Transmittal Lett r

GOMMISSIONER FOR PATENTS Washington, D.C. 20231

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Transmitted herewith for filing under 37 CFR 1.53(b) is a(n):(X)	Utility	()	Design
(X) c	original	pate	nt application,
()	continua	ation	-in-part application

INVENTOR(S): Osamu Samuel NAKAGAWA

TITLE:

PROCESS FOR HIGH-DIELECTRIC CONSTANT METAL-INSULATOR METAL CAPICATOR IN VLSI MULTI-LEVEL METALLIZATION SYSTEMS

Enclosed are: (X) The Declaration and Power of Attorney. (x) signed () unsigned or partially signed (X) 4 sheets of drawings (one set) () Associate Power of Attorney () Form PTO-1449 () Information Disclosure Statement and Form PTO-1449 () Priority document(s) () (Other) _____ (fee \$_____

CLAIMS AS FILED BY OTHER THAN A SMALL ENTITY						
(1) FOR	(2) NUMBER FILED	(3) NUMBER EXTRA	(4) RATE		5) 「ALS	
TOTAL CLAIMS	19 — 20	0	X \$18	\$	0	
INDEPENDENT CLAIMS	2 — 3	0	X \$80	\$	0	
ANY MULTIPLE DEPENDENT CLAIMS	0		\$270	\$	0	
BASIC FEE: Design (\$320.00); Utility (\$710.00)				\$	710	
TOTAL FILING FEE				\$	710	
OTHER FEES				\$		
TOTAL CHARGES TO DEPOSIT ACCOUNT			\$	710		

Charge \$___710____ to Deposit Account 08-2025. At any time during the pendency of this application, please charge any fees required or credit any over payment to Deposit Account 08-2025 pursuant to 37 CFR 1.25. Additionally please charge any fees to Deposit Account 08-2025 under 37 CFR 1.16, 1.17,1.19, 1.20 and 1.21. A duplicate copy of this sheet is enclosed.

the Ost .10 to: D.C.

Respectfully submitted,

Osamu Samuel NAKAGAWA

Attorney/Agent for Applicant(s)

Reg. No. 33,771
Date: June コム コロノ

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

UTILITY PATENT APPLICATION FOR:

PROCESS FOR HIGH-DIELECTRIC CONSTANT METALINSULATOR METAL CAPACITOR IN VLSI MULTI-LEVEL METALLIZATION SYSTEMS

Inventor:

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